| INTERNATIONAL SEARCH REPO | | PCT/IB2004/051040 | | 1 | |
|----------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|--------------------------------------------------------------------------------------------------------------------------------------------------------------|------------------------|------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|-----------------------|--|
| | | | | 4/051040 | |
| IPC 7 | HO1L29/778 HO1L29/15 | | | | |
| | o International Patent Classification (IPC) or to both national classification | tion and IPC | | | |
| | SEARCHED Currentation searched (classification system followed by classification | on symbols) | | | |
| IPC 7 | H01L | | | | |
| Documenta | tion searched other than minimum documentation to the extent that su | uch documents are inch | uded in the fields se | earched | |
| | ata base consulted during the international search (name of data base | e and, where practical | , search terms used |) | |
| E70-111 | ternal, INSPEC, WPI Data, PAJ | | | , | |
| C. DOCUM | ENTS CONSIDERED TO BE RELEVANT | | | | |
| Category * | ory * Citation of document, with indication, where appropriate, of the relevant passages | | | Relevant to claim No. | |
| x | US 4 908 678 A (YAMAZAKI SHUNPEI) 13 March 1990 (1990-03-13) | | 1-6,9, 10, 13-17,21 | | |
| Y | column 1, line 53 - column 2, line 22; figures 1,2 column 3, line 26 - line 38 | | 14,22 | | |
| | column 2, line 33 - line 44 | | | | |
| X | US 5 055 887 A (YAMAZAKI SHUNPEI) 8 October 1991 (1991–10–08) | | 1-6,9, 11, 13-17,21 | | |
| Y | column 1, line 66 - column 2, line 32; figures 1,2 column 3, line 57 - line 65 column 3, line 36 - line 49 column 1, line 66 - column 2, line 32 | | 14,22 | | |
| | | / | | | |
| | | | | | |
| Further documents are listed in the continuation of box C. X Patent family members are listed in annex. | | | | | |
| Special categories of cited documents: 'A' document defining the general state of the art which is not considered to be of particular relevance 'E' earlier document but published on or after the international filing date 'L' document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) 'O' document referring to an oral disclosure, use, exhibition or other means 'O' document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention 'X' document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such document, such combination being obvious to a person skilled in the art. | | | the application but sony underlying the latimed invention be considered to current is taken alone almed invention entive step when the re other such docu— | | |
| later than the priority date claimed '8' document member of the same patent family | | | | | |
| | Date of the actual completion of the international search Date of mailing of the international search report 5 October 2004 19/10/2004 | | | | |
| Name and mailing address of the ISA Authorized officer | | | | | |
| European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016 | | Gröger, A | | | |

INTERNATIONAL SEARCH REPORT

Intermonal Application No
PCT71B2004/051040

| offen) Pocliments Considered to be activistic | PCT71B2004/051040 |
|--------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|---------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|
| Citation of document, with indication, where appropriate, of the relevant passages | Relevant to claim No. |
| US 4 695 857 A (BABA TOSHIO ET AL) | 1-6,14, |
| 22 September 1987 (1987-09-22) column 6, line 3 - line 19; figures 1-14 column 9, line 34 - column 10, line 37 column 2, line 3 - line 4 column 5, line 34 - line 44 | 15,17, 18,21 |
| US 4 665 412 A (OHKAWA TIHIRO ET AL) 12 May 1987 (1987-05-12) column 2, line 29 - line 36; figures 1-5 column 3, line 1 - line 18 column 10, line 10 - line 31 column 13, line 39 - line 44 column 2, lines 64-66 column 12, line 3 - line 6 | 1-5, 14-18,21 |
| KOJI Y ET AL: "THE FORMATION OF RESONANCE TUNNEL DIVICE BY GAMMA-AL203/SI MULTIPLE HETROSTRUCTURE" EXTENDED ABSTRACTS OF THE INTERNATIONAL CONFERENCE ON SOLID STATE DEVICES AND MATERIALS, JAPAN SOCIETY OF APPLIED PHYSICS. TOKYO, JA, vol. 2001, 26 September 2001 (2001-09-26), pages 588-589, XP001074916 sections 1,2 abstract | 1,3-5,9, 14,15, 17,18,21 |
| LU Z H ET AL: "Crystalline <formula><roman>Si</roman>/<roman>Si0</roman><inf>2</inf> </formula> quantum wells" APPLIED PHYSICS LETTERS, AMERICAN INSTITUTE OF PHYSICS. NEW YORK, US, vol. 80, no. 2, 14 January 2002 (2002-01-14), pages 255-257, XP012030900 ISSN: 0003-6951 abstract page 255, left-hand column, line 19 - line 32 | 1,3-5,9, 14,15,21 |
| MEREU B ET AL: "Fowler-Nordheim tunneling in epitaxial yttrium oxide on silicon for high-k gate applications" 2002 INTERNATIONAL SEMICONDUCTOR CONFERENCE. CAS 2002 PROCEEDINGS (CAT. NO.02TH8618) IEEE PISCATAWAY, NJ, USA, | 14,15, 17-21 |
| Vol. 2, 8 October 2002 (2002-10-08), - 12 October 2002 (2002-10-12) pages 309-312 vol.2, XP002299184 ISBN: 0-7803-7440-1 section 3, paragraph 1 | |
| | US 4 695 857 A (BABA TOSHIO ET AL) 22 September 1987 (1987-09-22) column 6, line 3 - line 19; figures 1-14 column 9, line 34 - column 10, line 37 column 2, line 3 - line 4 column 5, line 3 - line 4 column 5, line 34 - line 44 US 4 665 412 A (OHKAWA TIHIRO ET AL) 12 May 1987 (1987-05-12) column 2, line 29 - line 36; figures 1-5 column 2, line 10 - line 31 column 10, line 10 - line 31 column 13, line 39 - line 44 column 2, lines 64-66 column 12, lines 3 - line 6 KOJI Y ET AL: "THE FORMATION OF RESONANCE TUNNEL DIVICE BY GAMMA-AL203/SI MULTIPLE HETROSTRUCTURE" EXTENDED ABSTRACTS OF THE INTERNATIONAL CONFERENCE ON SOLID STATE DEVICES AND MATERIALS, JAPAN SOCIETY OF APPLIED PHYSICS. TOKYO, JA, vol. 2001, 26 September 2001 (2001-09-26), pages 588-589, XP001074916 sections 1,2 abstract LU Z H ET AL: "Crystalline <formula><roman>S1</roman>/<roman>S10<1nf>2 LU Z H ET AL: "Crystalline *formula><roman>S1 *roman>S1 /roman>S10 *NOI. 80, no. 2, 24 4 January 2002 (2002-01-14), pages 255-257, XP012030900 ISSN: 0003-6951 abstract page 255, left-hand column, line 19 - line 32 MEREU B ET AL: "Fowler-Nordheim tunneling in epitaxial yttrium oxide on silicon for nigh-k gate applications" 2002 INTERNATIONAL SEMICONDUCTOR CONFERENCE. CAS 2002 PROCEEDINGS (CAT. NO.02TH8618) IEEE PISCATAWAY, NJ, USA, vol. 2, 8 October 2002 (2002-10-08), - 12 October 2002 (2002-10-12) pages 309-312 vol. 2, 8 October 2002 (2002-10-08), - 12 October 2002 (2002-10-12) pages 309-312 vol. 2, POO2299184 ISBN: 0-7803-7440-1</roman></roman></formula> |